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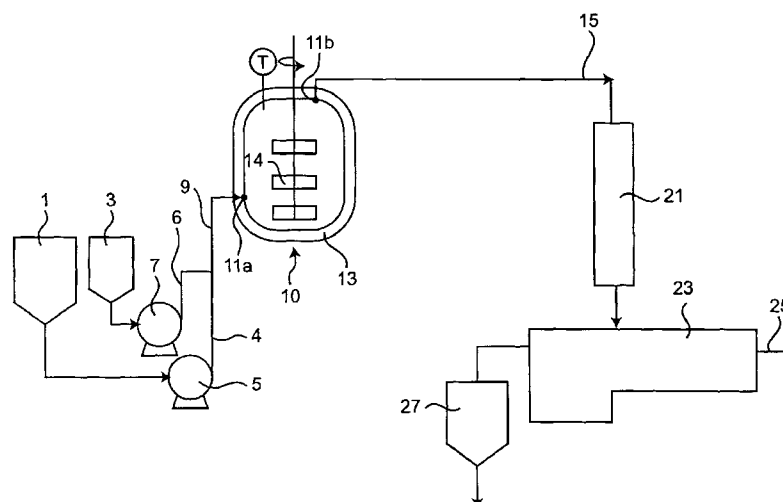
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(54) **Title:** PROCESS FOR PRODUCING METHACRYLIC POLYMER COMPOSITION

Figure 1



(57) **Abstract:** The present invention provides a process for producing a methacrylic polymer composition, which comprises supplying a raw material mixture comprising a raw material monomer containing 50% by weight or more of methyl methacrylate and a polymerization initiator into a reactor of a complete mixing type through a supply port thereof; subjecting to continuous polymerization in the reactor; and taking an obtained polymer composition from an effluent port thereof, wherein a temperature of the raw material mixture supplied into the reactor is -50°C to -10°C. By this, a methacrylic polymer composition suitable for producing a high thermally-stable and heat-resistant resin composition with high quality can be produced.